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DATE MAILED: 11/29/2005

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)	1
Office Action Comments	10/661,051	GALLAGHER ET AL.	//~
Office Action Summary	Examiner	Art Unit	
	Kin-Chan Chen	1765	
The MAILING DATE of this communication app Period for Reply	ears on the cover sheet with the	ne correspondence address -	-
A SHORTENED STATUTORY PERIOD FOR REPLY WHICHEVER IS LONGER, FROM THE MAILING DA  - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication.  - If NO period for reply is specified above, the maximum statutory period v  - Failure to reply within the set or extended period for reply will, by statute, Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	ATE OF THIS COMMUNICAT 36(a). In no event, however, may a reply by the state of the	TON.  be timely filed  from the mailing date of this communica  ONED (35 U.S.C. § 133).	·
Status			
1) Responsive to communication(s) filed on 24 O	ctober 2005.		
	action is non-final.		
3) Since this application is in condition for allowar	nce except for formal matters,	prosecution as to the merits	is is
closed in accordance with the practice under E	Ex parte Quayle, 1935 C.D. 11	, 453 O.G. 213.	
Disposition of Claims		•	
4)⊠ Claim(s) <u>1-13 and 19</u> is/are pending in the app	lication.		
4a) Of the above claim(s) is/are withdraw			
5) Claim(s) is/are allowed.			
6)⊠ Claim(s) <u>1-13 and 19</u> is/are rejected.			
7) Claim(s) is/are objected to.			
8) Claim(s) are subject to restriction and/or	r election requirement.		
Application Papers			
9) The specification is objected to by the Examine	r.		
10) The drawing(s) filed on is/are: a) acce	epted or b) objected to by the	ne Examiner.	
Applicant may not request that any objection to the	drawing(s) be held in abeyance.	See 37 CFR 1.85(a).	
Replacement drawing sheet(s) including the correct	* * * * * * * * * * * * * * * * * * * *	•	• •
11) The oath or declaration is objected to by the Ex	aminer. Note the attached Off	fice Action or form PTO-152.	•
Priority under 35 U.S.C. § 119			
12) Acknowledgment is made of a claim for foreign	priority under 35 U.S.C. § 119	9(a)-(d) or (f).	
a) ☐ All b) ☐ Some * c) ☐ None of:			
1. Certified copies of the priority documents	s have been received.		
2. Certified copies of the priority documents	s have been received in Applic	cation No	
3. ☐ Copies of the certified copies of the prior	· •	eived in this National Stage	
application from the International Bureau	` ' ' '		
* See the attached detailed Office action for a list	of the certified copies not rece	eived.	
Attachment(s)			
1) Notice of References Cited (PTO-892)	4) Interview Summ		
2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08)	Paper No(s)/Ma 5) Notice of Inform	il Date at Patent Application (PTO-152)	
Paper No(s)/Mail Date <u>102405</u> .	6) Other:		
U.S. Patent and Trademark Office PTOL-326 (Rev. 7-05)  Office Ac	tion Summary	Part of Paper No./Mail Date 112	 2805

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#### **DETAILED ACTION**

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### Claim Rejections - 35 USC § 103

- 1. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
  - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 2. Claims 1-13 and 19 are rejected under 35 U.S.C. 103(a) as being unpatentable over Besling et al. (US 6,562,732; hereinafter "Besling") in view of Odian (p.18, "Principles of Polymerization", 1981, second edition) and Allen et al. (US 6,420,441; hereinafter "Allen").

In a method of manufacturing a device, Besling teaches that a sacrificial material layer may be disposed on a device substrate. An overlayer (e.g., porous dielectric) material may be disposed on the sacrificial material layer. The sacrificial material layer may be removed to form an air gap. The sacrificial material layer may comprise a polymer (abstract; col. 2, lines 34-44; Figures). Besling teaches using a polymer as sacrificial material. Besling cites some examples. The disclosure of Besling is not limited to any type of polymer. In the book of "Principles of Polymerization", Odian teaches that polymers may be linear, branched, or cross-linked polymers (p.18). Hence, it would have been obvious to one with ordinary skill in the art to use a cross-linked

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polymer in the process of Besling because it is one of the most popular polymers used in the industry and because it is taught by Odian. Since the combined prior art of Besling and Odian teaches cross-linked polymers, it would have been obvious to one with ordinary skill in the art to use commercially available (well-known) cross-linker such as multi-ethylenically unsaturated monomer. Allen (col. 8, lines 25-58) is only relied on to show some well-known cross-linkers. Hence, it would have been obvious to one with ordinary skill in the art to incorporate cross-linker of multi-ethylenically unsaturated monomer in the process of modified Besling and Odian because it is well-known cross-linker and because it is disclosed by Allen.

The examiner recognizes that obviousness can only be established by combining or modifying the teachings of the prior art to produce the claimed invention where there is some teaching, suggestion, or motivation to do so found either in the references themselves or in the knowledge generally available to one of ordinary skill in the art. See In re Fine, 837 F.2d 1071, 5 USPQ2d 1596 (Fed. Cir. 1988) and In re Jones, 958 F.2d 347, 21 USPQ2d 1941 (Fed. Cir. 1992). In this case, because it is a well-known (commercially available) feature, therefore, it is in the knowledge generally available to one of ordinary skill in the art.

The limitations of claims 1, 4, 6, 10, 11, 12, 13, and 19 have been addressed above and rejected for the same reasons, supra.

As to claim 2, Besling teaches using a porous dielectric material as the overlay material, making an organic polysilica (organosilanes) material obvious because it is a well-known dielectric material in device fabrication.

As to claim 5, see col. 4, lines 4-5.

As to claim 8, see Figures.

As to claim 9, Besling teaches using polymer including UV photoresist material may be used as sacrificial material, making curing the sacrificial material composition for forming the sacrificial material obvious.

The above-cited claims differ from the prior art by specifying well-known features (such as cross-linked polymers in claims 3 and 7) to the art of device fabrication. It is the examiner's position that a person having ordinary skill in the art at the time of the claimed invention would have found it obvious to modify the prior art by adding any of same well-known features to same in order to fabricate an easily removable sacrificial material layer with a reasonable expectation of success. The examiner takes official notice of facts that applicant did not traverse the aforementioned conventionality (e.g., well-known features, common knowledge, obviousness), which have been stated in the previous office action ( July 15, 2005).

3. Claims 1-13 and 19 are rejected under 35 U.S.C. 103(a) as being unpatentable over Babich et al. (US 6,815,329; hereinafter "Babich") in view of Odian (p.18, "Principles of Polymerization", 1981, second edition) and Allen et al. (US 6,420,441; hereinafter "Allen").

In a method of manufacturing a device, Babich teaches that a sacrificial material layer may be disposed on a device substrate. An overlayer (e.g., porous dielectric) material may be disposed on the sacrificial material layer. The sacrificial material layer may be removed to form an air gap. The sacrificial material layer may comprise a polymer (col. 8 and 9; Figures). Babich teaches using a polymer as

sacrificial material. The disclosure of Babich is not limited to any type of polymer. In the book of "Principles of Polymerization", Odian teaches that polymers may be linear, branched, or cross-linked polymers (p.18). Hence, it would have been obvious to one with ordinary skill in the art to use a cross-linked polymer in the process of Babich because it is one of the most popular polymers used in the industry and because it is taught by Odian. Babich cites some examples. The disclosure of Babich is not limited to any type of polymer. In the book of "Principles of Polymerization", Odian teaches that polymers may be linear, branched, or cross-linked polymers (p.18). Hence, it would have been obvious to one with ordinary skill in the art to use a cross-linked polymer in the process of Babich because it is one of the most popular polymers used in the industry and because it is taught by Odian. Since the combined prior art of Babich and Odian teaches cross-linked polymers, it would have been obvious to one with ordinary skill in the art to use commercially available (well-known) cross-linker such as multiethylenically unsaturated monomer. Allen (col. 8, lines 25-58) is only relied on to show some well-known cross-linkers. Hence, it would have been obvious to one with ordinary skill in the art to incorporate cross-linker of multi-ethylenically unsaturated monomer in the process of modified Babich and Odian because it is well-known cross-linker and because it is disclosed by Allen.

The examiner recognizes that obviousness can only be established by combining or modifying the teachings of the prior art to produce the claimed invention where there is some teaching, suggestion, or motivation to do so found either in the references themselves or in the knowledge generally available to one of ordinary skill in the art. See In re Fine, 837 F.2d 1071, 5 USPQ2d 1596 (Fed. Cir. 1988) and In re Jones, 958 F.2d 347, 21 USPQ2d 1941 (Fed. Cir. 1992). In this case, because is a well-known (commercially available) feature, therefore, it is in the knowledge generally available to one of ordinary skill in the art.

The limitations of claims 1, 4, 6, 10, 11, 12, 13, and 19 have been addressed above and rejected for the same reasons, supra.

As to claim 2, Babich teaches using a porous dielectric material as the overlay material, making an organic polysilica (organosilanes) material obvious because it is a well-known dielectric material in device fabrication (col.9, lines 41-58.

As to claim 5, see col. 8, lines 64-66.

As to claim 8, see Figures.

The above-cited claims differ from the prior art by specifying well-known features (such as cross-linked polymers in claims 3 and 7; applying and curing a cross-linkable polymer in claim 9) to the art of device fabrication. It is the examiner's position that a person having ordinary skill in the art at the time of the claimed invention would have found it obvious to modify the prior art by adding any of same well-known features to same in order to fabricate an easily removable sacrificial material layer with a reasonable expectation of success. The examiner takes official notice of facts that applicant did not traverse the aforementioned conventionality (e.g., well-known features, common knowledge, obviousness), which have been stated in the previous office action (July 15, 2005).

## Response to Arguments

4. Applicant's arguments filed October 24, 2005 have been fully considered but they are not persuasive.

Applicant has argued that Besling (or Babich) only cited some polymers such as PMMA, polystyrene, and polyvinyl alcohol. No other polymers are taught or suggested. It is not persuasive. As has been stated in the office action, Besling (or Babich) cites some examples. The disclosure of Besling (Babich) is not limited to any type of polymer. In the book of "Principles of Polymerization", Odian teaches that polymers may be linear, branched, or cross-linked polymers (p.18).

However, reference's disclosure is not limited to the exemplified (materials) / process parameters (e.g., preferred pressure range or temperature range). See In re Fracalossi, 681 F.2d 792, 794 n.1, 215 USPQ 569, 570 n.1 (CCPA 1982).

The broad interpretation of the patentee's limitation "polymer' is one which encompasses linear, branched, or cross-linked polymers as described in textbook of Odian. This is particularly true given that terms must be given their broadest reasonable interpretation consistent with, but not improperly limited.

Johnson Worldwide Assocs., Inc. v. Zebco Corp., 175 F.3d985, 989 (Fed.Cir. 1999).

Applicant has argued that Besling teaches that the polymer may be removed by heating, therefore, it does not suggest that the polymers are more thermally stable. It is not persuasive. In fact, Besling suggests the polymer may be decomposed by heat at 400°C, which is in the same temperature range as applicant's disclosure (p. 14, last paragraph and P. 20, last paragraph) for removing the sacrificial materials (polymers).

#### Conclusion

5. Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, **THIS ACTION IS MADE FINAL**. See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

6. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Kin-Chan Chen whose telephone number is (571) 272-1461. If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Nadine Norton can be reached on (571) 272-1465. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306. Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published

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applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

November 28, 2005

Kin-Chan Chen Primary Examiner Art Unit 1765